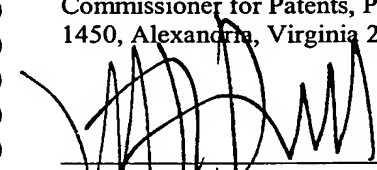




1 FW

PATENT
30205/39719

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Seong Hwan Park et al.)	I hereby certify that this paper and the
)	documents referred to as enclosed
Serial No.: 10/718,277)	therewith are being deposited with the
)	United States Postal Service as first class
Filed: November 20, 2003)	mail, postage prepaid, on September 30,
)	2004 , in an envelope addressed to
For: Photoresist Removing)	Commissioner for Patents, P.O. Box
Compositions)	1450, Alexandria, Virginia 22313-1450
)	
Group Art Unit: 1752)	Michael R. Hull
)	Reg. No. 35,902
Examiner: Hoa Van Le)	Attorney for Applicants

COMMENT ON STATEMENT OF REASONS FOR ALLOWANCE

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

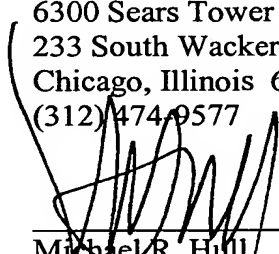
In addition to the reasons for allowance set forth in the allowance papers that were mailed in connection with the present application, it is respectfully submitted that the claims are allowable for the additional reasons that the invention defined by the language of the claims is neither anticipated by, nor would have been obvious when taken as a whole in view of, the art of record.

Respectfully submitted,

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September 30, 2004

By:


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